

**AMENDMENTS TO THE SPECIFICATION**

**On page 1, please replace the second paragraph starting at line 15 with the following rewritten one:**

The present invention relates to a method for setting firing temperature of cerium carbonate which is to be fired to produce a cerium oxide abrasive, a method for producing high-purity cerium oxide abrasives for planarization of semiconductors, and to abrasive ~~lots~~reeds produced through the method.

**On page 7, please replace the third full paragraph starting at line 14 with the following rewritten one:**

(7) Cerium oxide abrasive ~~reeds~~lots produced through the method as set forth in any one of (3) to (5) above, wherein the cerium oxide abrasive ~~reeds~~lots contain soluble fluorine in an amount falling within a range of 20 to 1000 ppm by mass based on the mass of the cerium oxide.

**On page 7, please replace the fourth full paragraph starting at line 19 with the following rewritten one:**

(8) The cerium oxide abrasive ~~reeds~~lots as recited in (7) above, wherein the cerium oxide abrasive ~~reeds~~lots comprises cerium oxide abrasives having a specific surface area falling within a range of 9.5 to 12.2 m<sup>2</sup>/g.

**On page 7, please replace the fifth full paragraph starting at line 23 with the following rewritten one:**

(9) A cerium oxide abrasive slurry comprising cerium oxide, water and a dispersant capable of dispersing cerium oxide, wherein said cerium oxide is obtained from the cerium oxide abrasive ~~reeds~~lots as set forth in (7) or (8) above.

**Please replace the paragraph bridging pages 8 and 9, with the following rewritten one:**

Thus, by controlling the firing temperature of cerium carbonate serving as a raw material in accordance with the fluorine content of the raw material, the produced cerium oxide ~~reeds~~lots have excellent quality (i.e., crystal quality and specific surface area), with less variation thereof

within the ~~red~~slots, comparable to that of cerium oxide produced from pure cerium carbonate as a raw material.

**On page 13, please replace the second full paragraph starting at line 19 with the following rewritten one:**

The range of modifying the firing temperature in accordance with the fluorine content is generally about 10°C to about 50°C. Thus, in the production of cerium oxide ~~red~~slots, for each of which a firing test should have been conducted in many cases, a means for determining the firing temperature in accordance with the fluorine content is advantageous from the viewpoint of enhancement of production efficiency and reduction of variation in quality.